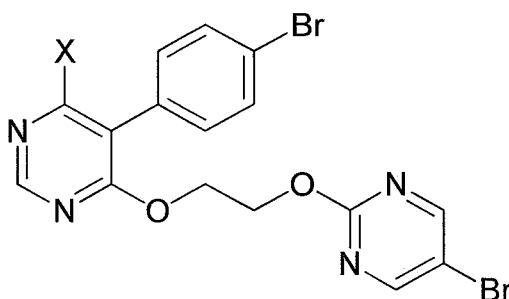


2. The process of claim 1, wherein the base is selected from the group consisting of NaOH, KOH, 1,8-diazabicyclo[5.4.0]undec-7-ene, triethylamine, potassium *tert*-butylate, Na₂CO₃, K₂CO₃ and Cs₂CO₃.
3. The process of claim 2, wherein the base is K₂CO₃.
- 5 4. The process of one of claims 1 to 3, wherein the polar aprotic organic solvent or polar mixture of aprotic organic solvents comprises dimethylsulfoxide.
5. The process of claim 4, which is performed using dimethylsulfoxide as solvent.
6. The process of one of claims 1 to 5, wherein X is chlorine and the reaction of the compound of formula I-1 with the compound of formula I-2 is performed in the presence
10 of tetra-*n*-butyl ammonium fluoride hydrate and using dimethylsulfoxide as solvent.
7. A compound of formula I-1



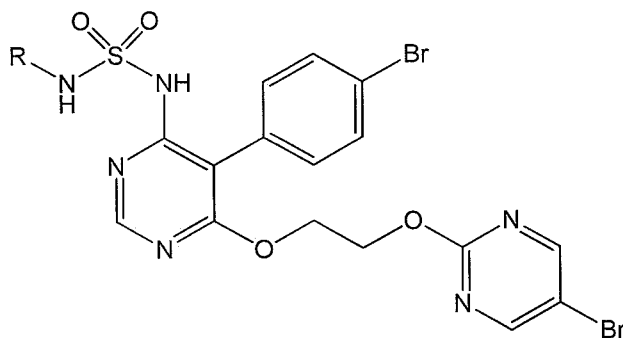
I-1

wherein X is fluorine;

or a salt of said compound.

8. Use of a compound of formula I-1 according to claim 7, or of a salt thereof, in a process for manufacturing the compound of formula I as defined in claim 1, or a salt thereof.

9. A process for manufacturing the compound of formula I

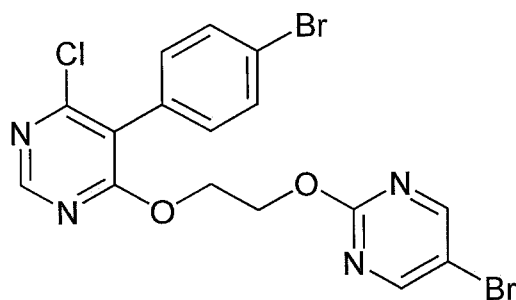


5

I

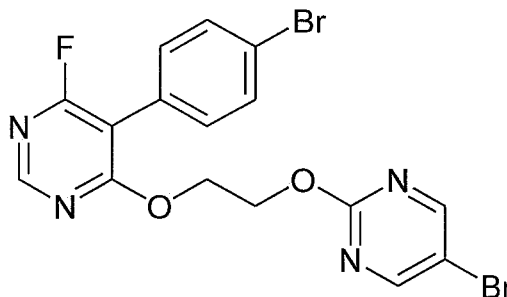
wherein R is H, or for manufacturing a salt thereof, said process comprising the reaction of the compound of formula I-1, said process comprising the following steps:

a) the reaction of the compound of formula I-1_{Cl}



I-1_{Cl}

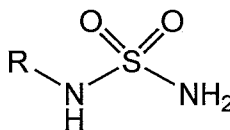
or a salt thereof, with tetra *n*-butyl ammonium fluoride hydrate or cesium fluoride in the presence of a base in a polar aprotic organic solvent or a polar mixture of aprotic organic solvents, to yield the compound of formula I-1_F



I-1_F

and

- 5 b) the reaction of the compound of formula I-1_F obtained at step a) with a compound of formula I-2



I-2

wherein R is H, or a salt thereof, in the presence of a base in a polar aprotic organic solvent or a polar mixture of aprotic organic solvents, to yield said compound of formula I or a salt thereof.

- 10 **10.** The process of claim 9, wherein step a) is performed by reacting the compound of formula I-1_{Cl} with cesium fluoride.